Mechanisms of Electrocatalytic Reduction of N₂ at Vanadium and Cobalt Oxynitride Surfaces: Impacts of Metal Oxophilicity and π -Backbonding

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The electrochemical reduction of N_2 to NH_3 —the nitrogen reduction reaction (NRR) –is of burgeoning interest as an environmentally/energy-friendly alternative to the Haber-Bosch process, which currently accounts for $\sim 2\%$ of the world's energy consumption, with heavy consumption of 100 fossil fuels due to running at elevated 7000 (b) (a) V(IV **01s** temperatures [1]. Earth-abundant oxides and O2s V(III V(II) oxynitrides have been the objects of intensive study over the last 3 years, but major **≠2**p_{3/2} O2p uncertainties remain, including (a) the roles of

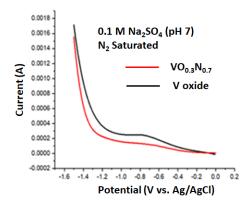


Fig. 2. Electrochemical polarization curves for N-free vanadium oxide (black trace) and for a VO_{0.3}N_{0,7} film. From [6].

but also selectivity against the Hydrogen Evolution Reaction (HER).

To begin to explore this area in a systematic manner, we have prepared vanadium oxynitride (VO_xN_{1-x}) and CoO_xN_{1-x} films (0<x<1), characterized by AES, XRD, and XPS, using magnetron sputter deposition [2, 3]. Variations in O_2/N_2 plasma pressures have been used to systematically vary x [2, 3]. Electrochemical polarization measurements have been carried out in pH 7 0.1 M Na₂SO₄ electrolytes to minimize HER effects. In general, the vanadium oxide and oxynitride films exhibit similar V 2p and O1s core level spectra (e.g., Fig. 1 for x = 1)[3, 4] with V in both +3 and +4 oxidation states. Oxynitride films (x < 1) exhibit N 1s peak binding energies near 397.0 eV [3] in close agreement with previous studies of VN films (not shown) [5]. Electrochemical polarization curves (Fig.

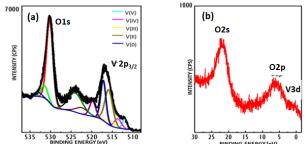


Fig. 1 XPS spectra of a Vanadium oxide film prior to immersion in electrolyte: (a) O 1s/V2p ; (b) valence band. Both V(III) and V(IV) are present. From [4]

O-metal and N-metal interactions in the NRR process, and (b) the effects of π -backbonding in metal-N₂ adsorption and reactions.

Such factors may impact not only NRR activity,

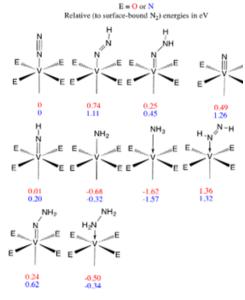
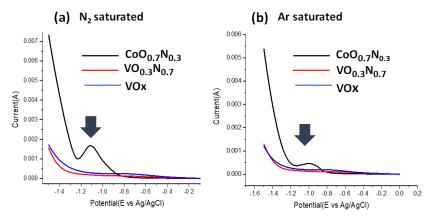


Fig. 3 Configurations of various possible N/H intermediates in NRR. Calculated relative energies (in eV) are also shown relative to that of surface bound N₂ are shown for both E = O (red), $[V]_0$, and E =

2) are similar for both species, though slightly higher for the N-rich film. (The direct production of NH₃ was confirmed by absorption spectroscopy.) This is consistent with our findings that both lattice N and

solvated N₂ undergo reduction predominantly at O-supported vanadium centers (V₀) rather than at Nsupported vanadium centers (V_N) [6]. DFT-based calculations [4] indicate that N₂ adsorption and protonation are energetically favored at V₀ vs. V_N centers (Fig. 3) consistent with the somewhat enhanced activity for the vanadium oxide film vs. the oxynitride film (Fig. 3).



in Figs. 1-3 demonstrate that for oxophilic metals, Vo sites are preferred vs. V_N sites for N₂ adsorption and reaction, although this preference may become less pronounced for less oxophilic metals toward the right of the periodic table. Metals toward the right of the periodic table,

The data

Fig. 4 EC polarization curves for CoOxNy (black trace), VO_{0.3}N_{0.7} (red) and V oxide (blue). Same conditions as in Fig. 3. Region near -1.1 V (arrow) shows greater intensity in N₂-saturated vs. H₂-saturated solution, indicating NRR selectivity. NH₃ detected by absorption spectroscopy (not shown). (Unpublished

however, exhibit greater 3d-orbital occupancy for cations of comparable charge (e.g., Co(III) vs. V(III)), suggesting greater π -backbonding, which should enhance N₂-M attraction and weaken NN bonds, thus enhancing initial N protonation. Electrochemical polarization curves (Fig. 4) show an <u>order of magnitude</u> <u>increase in NRR activity</u> in N₂-saturated pH 7 electrolyte for Co_{0.7}N_{0.3}. Further, regions near -1.1 V vs Ag/AgCl (arrow, Fig. 4) show greater intensity in N₂-vs.H₂-saturated solution, indicating significant selectivity for NRR. The data demonstrate greatly enhanced NRR activity and selectivity for the CoOxNy film, strongly suggesting the importance of M-N₂ π -backbonding in NRR. This relationship is being explored in experiments underway in our laboratories.

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